				Docket Number (Optional) SWO-0002		Application Number					
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HMC		2002-79605	03/19/2002	JAPAN							
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HME		Office Action by Chine	Office Action by Chinese Patent Office dated July 29, 2005.								
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HMC		6,683,720 B2	01/27/2004	Yoshida et al.							
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HWC		2000-056137	2/25/2000	JAPAN							
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